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Dr. Hu Jiansheng, Professor, Deputy director of Tokamak Physics Division, group leader of Vacuum Technology and Wall Conditioning.

Born in 1973 in Anhui province, China. Obtained bachelor's degree in the department of electronic engineering in Xi'an Jiaotong Univ. in 1994, majoring in Vacuum Electronic and Physics Devices. Obtained Mater's degree in 1998 and Obtained Ph'D in 2008 in ASIPP, majoring in Fusion Engineering and Plasma Physics.

Fields of interest are Plasma and Wall Interaction (wall conditioning, plasma facing components design, etc.) and Vacuum Science and Technology. Designed movable Mo pumping limiter, high performance toroidal graphite actively cooled limiters with CrCu heat sink, guard limiters of LHCD antenna, and liquid lithium limiter for HT-7. Analyzed plasma facing materials deposition, erosion and dusts in HT-7 and EAST. Investigation of wall conditionings, such as baking, GDC and ICRF cleanings, Boronization, Lithium coating in HT-7 and EAST. Investigation of oxidation wall conditionings associated with baking, GDC and ICRF for deposits removal and hydrogen release. Pumping system, gas puffing system and wall conditioning system development and operation for HT-7 and EAST.

Visited Italy, Japan, Germany and Spain and attended international conference more than 10 times. In charge of one project from National Nature Science Foundation of China. Published paper over than 50.

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胡建生 安徽怀宁人，一九七三年出生，博士、研究员、博导，托卡马克物理实验室副主任，托卡马克装置真空与壁处理课题组组长。

1994年毕业于西安交通大学电子工程系真空电子与物理器件专业，获工学学士学位。分别于1998年和2008年在中科院等离子体物理研究所获得核聚变工程硕士学位和等离子体物理实验理学博士学位。

主要研究方向为等离子体与壁相互作用（第一壁设计、壁处理及相关PSI研究等）和真空科学与技术。近年来的工作主要侧重于HT-7装置第一壁设计与研究、壁处理技术与物理机制的研究。负责设计了HT-7装置钼抽气限制器，高性能水冷石墨限制器，低杂波天线保护限制器，液态锂限制器等。分析第一壁腐蚀、沉积及灰尘等。在HT-7和EAST装置上研究了烘烤、直流辉光放电清洗、离子回旋放电清洗、硼化及锂化壁处理等；研究了不同热壁氧化壁处理对再沉积层清除和氢同位素清除效果与机制。负责HT-7和EAST装置抽气系统、充气系统、壁处理系统运行和发展。

出访意大利、日本、德国、西班牙等国十余次。负责国家自然科学基金一项。迄今为止在国内外刊物、会议上共发表学术论文50余篇。可招收等离子体物理、物理电子技术、真空技术、机械设计、材料等相关专业硕士、博士。

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